

ATOMIC LAYER DEPOSITION TOOL OVERVIEW

PROMETHEUS is the latest iteration of Forge Nano's cutting-edge powder ALD research tools. Our engineers have spent the last 10 years designing, optimizing, and improving this system to make it the best powder ALD research tool on the market. The **PROMETHEUS** series is the best choice for any researcher looking for a reliable powder ALD tool that enables truly scaleable commercial applications.



We realized the power of PROMETHEUS immediately in our research.
Using PROMETHEUS makes ALD research easy, intuitive and reliable.

DESIGNED FOR

POWDERS
 Every single grain of powder is coated uniformly.

• EASE OF USE

Recipe-based control system enables experiments at the click of a button

• VERSATILITY

Process a wide range of micro and nano

powders from grams to kilograms

and additional optional features.

• CUSTOMIZATION

Multiple dosing channels, 3 reactor sizes,

Forge Nano is delivering **PROMETHEUS** around the world to enable a new generation of advanced materials. With a virtual white-space environment for intellectual property development, the pressure is on to discover the next materials science breakthrough, and Prometheus is the tool to make it happen.







TECHNICAL SPECIFICATIONS

Forge Nano's **PROMETHEUS** tool is world's most reliable, flexible, and economical Particle Atomic Layer Deposition (ALD) R&D system. **PROMETHEUS** tools facilitate groundbreaking R&D and new product development, while enabling IP generation.

Key Specs	PROMETHEUS models	P-2L	P-2	P-4	P-6	P-8
Vapor Draw Sources	Basic Precursor Delivery	2	2	2	4	4
	Low Vapor Pressure Precursor Delivery	=	æ	2	2	4
Reactor Style	Vibrating Fluidized Bed Reactor					
Reactor Construction	Stainless Steel Body w/metal seals					
Reactor Temperature Range	Up to 450 ℃					
Maximum Process Line Temperatures	Up to 200 ℃	Standard				
Abatement Module	Foreline Traps, Filtration Unit	1 19				
MMI	Computer included with custom software					
Options: √ - Included o - available upgrade	Heat Jacketing *Basic insulation on P-2L					
	Rotary Vane Vacuum Pump		J	1	1	1
	Mass Spectrometer					
	Fluidization Aids (Jet Assist)		o	o	o	1
	Reactor Design for Inert Handling in Glovebox *not for use on late reactor (glovebox not included)			0		
	Ozone Generator					1
*Mass spectrometer and rotary vane vacuum pump removable upon request			1			
Available reactor sizes (usable	e powder volume range): Small (0.5mL) Medium (12-150mL) Large (100-6	600mL)				

All Prometheus Tools include: Heated manifold for consistent precursor vaporization, multiple fluidization aids for uniform coating, prescribed operating boundaries, emergency stop logic, customized recipes for rapid innovation, multiple precursor zones for independent heating of solid and low-vapor pressure precursor, isolation valves for air-free handling of sensitive powders and coatings.

Forge Nano is a global leader in atomic layer deposition for advanced materials. Our suite of patented, high-throughput ALD processes and tools take ALD from lab-scale research, all the way through commercial-scale manufacturing. We design, build, and implement ALD systems of any scale, enabling the next generation of product technology. Our customers & partners include: Volkswagen, LG Corporation, Mitsui Kinzoku, University of Maryland, Oakridge National Laboratory and Argonne National Laboratory among others. Visit our website to learn more about Forge Nano, and ALD technology. www.ForgeNano.com





